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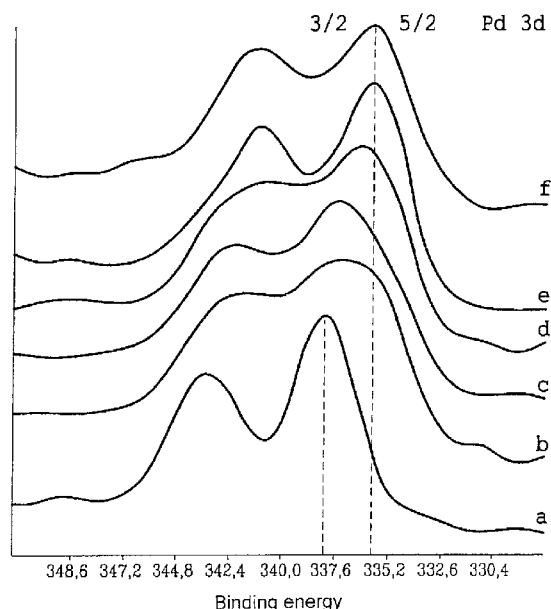
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(54) Title: PROCESS FOR METALLISING SUPPORT MEDIA MADE FROM PLASTIC MATERIAL



- a: PBT+plasma NH_3 + PdCl_2
b: PBT+plasma NH_3 + PdCl_2 + H_2PO_2 : 3min
c: PBT+plasma NH_3 + PdCl_2 + H_2PO_2 : 5min
d: PBT+plasma NH_3 + PdCl_2 + H_2PO_2 : 10min
e: PBT+plasma NH_3 + PdCl_2 + H_2PO_2 : 15min
f: PBT+plasma NH_3 + PdCl_2 + H_2PO_2 : 30min

(57) Abstract: In order to metallise a support made from high temperature polymer, the melting temperature of which is higher than 180°C, it is shown that the stages of cleaning, plasma etching, grafting and then metallising in a metallisation bath can be applied. According to the invention, the metallisation bath is brought to a temperature between 50°C and 70°C, the plasma being a nitrogenous plasma.



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